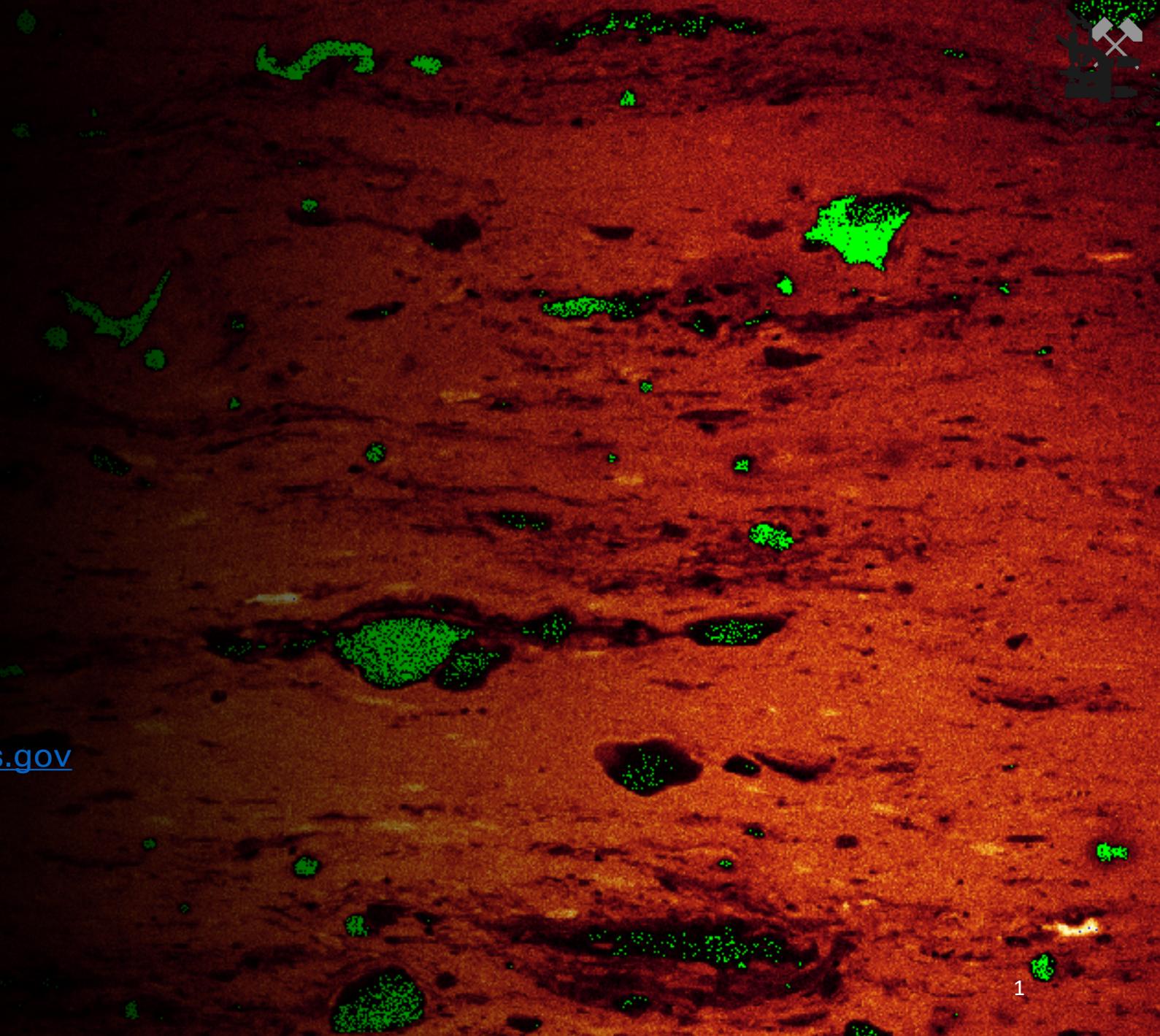




Confocal Laser Scanning Microscopy (CLSM) Working Group: Final Report 2021

Paul C. Hackley, USGS, phackley@usgs.gov

Jolanta Kus, BGR, jolanta.kus@bgr.de



Outline

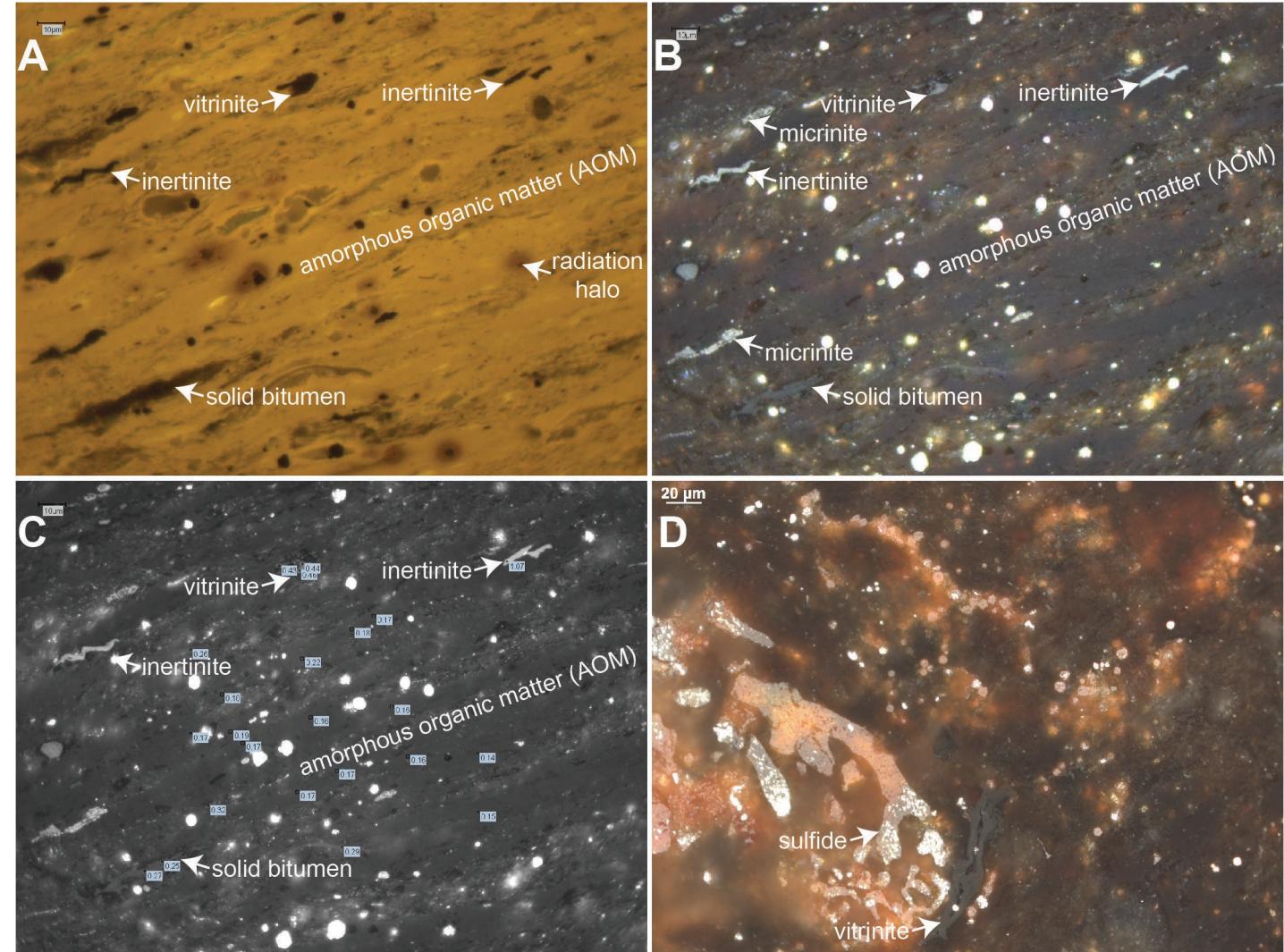
- ❑ History of the WG
- ❑ Sample used in WG
- ❑ AFM/ion milling characterization
- ❑ CLSM results
- ❑ Outcomes and Summary



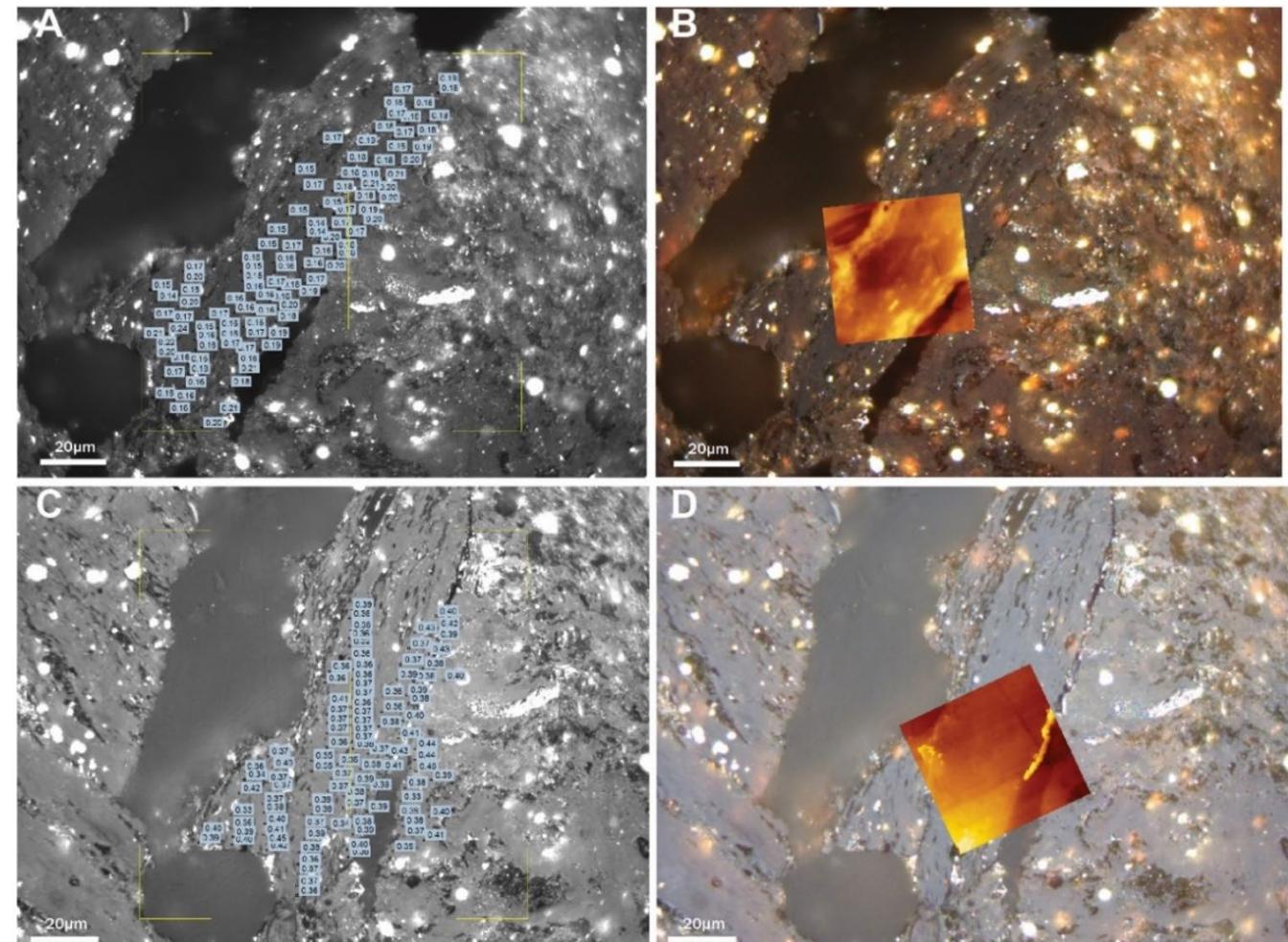
History of the CLSM WG

- ❑ Established Potsdam 2015
- ❑ Call for participants ICCP News No. 63 (Nov. 2015)
- ❑ Questionnaire February 2016
- ❑ Additional participants from 2016 GSA, 2016 ICCP (total 16)
- ❑ Kimmeridge Clay (KC) selected for ILS in 2017
- ❑ KC sample distributed April 2018
- ❑ Initial KC results presented Brisbane 2018
- ❑ Efforts to rejuvenate WG discussed The Hague 2019
- ❑ Covid 2020
- ❑ Video meetings of the convenors in 2021
- ❑ No interest from WG members to continue in 2021
- ❑ Decision to close WG 2021

Sample used in CLSM WG

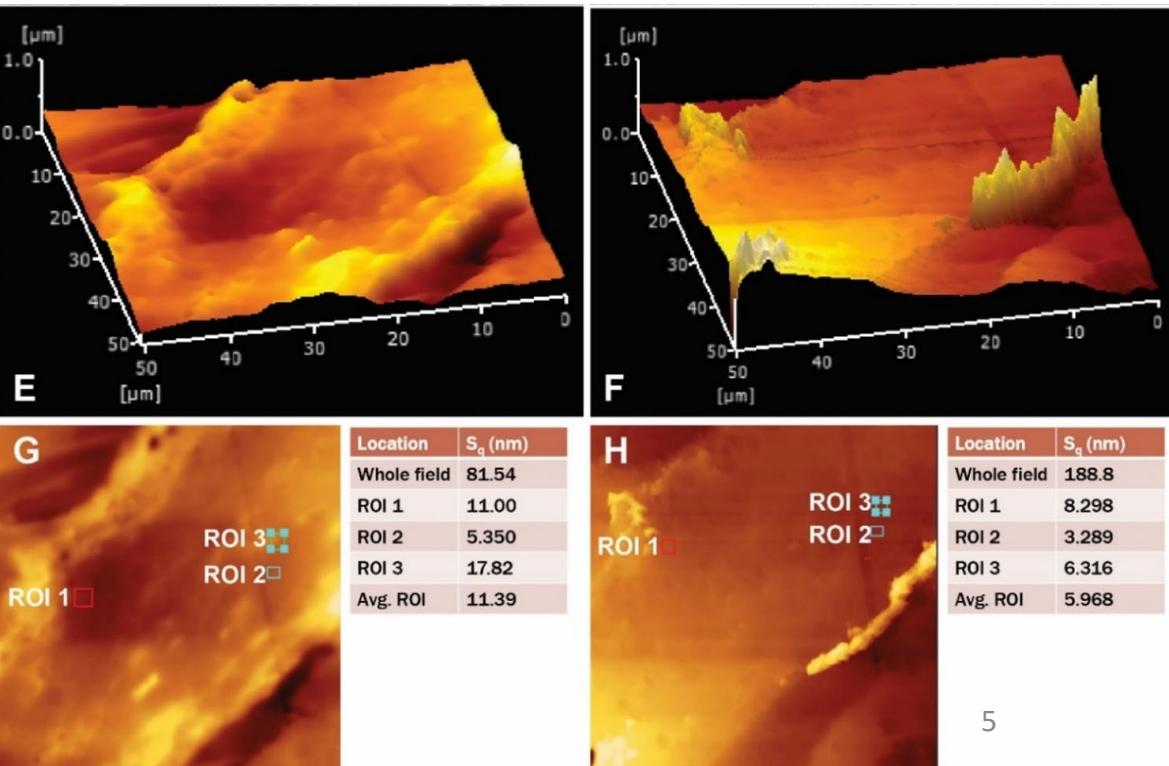


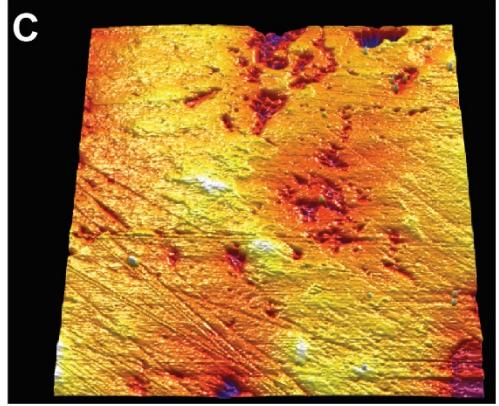
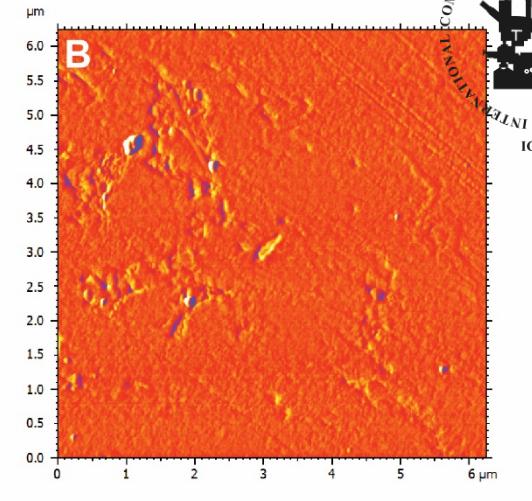
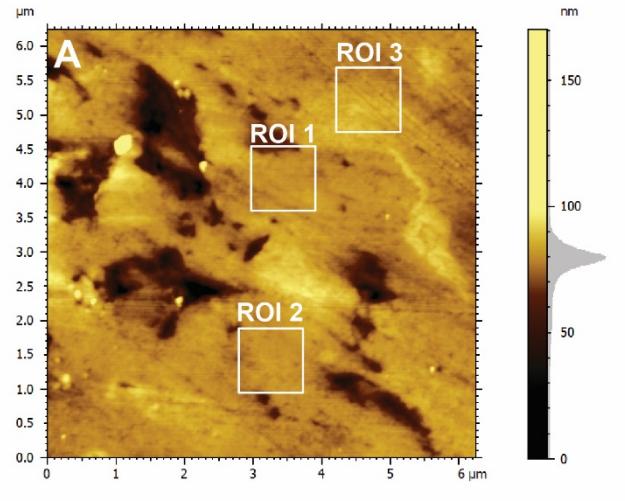
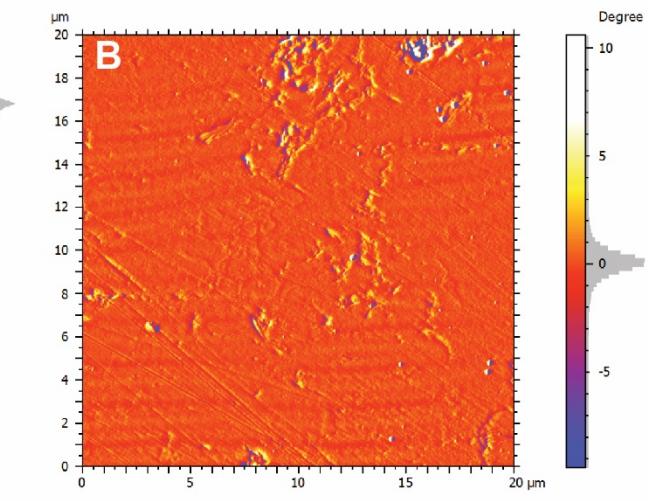
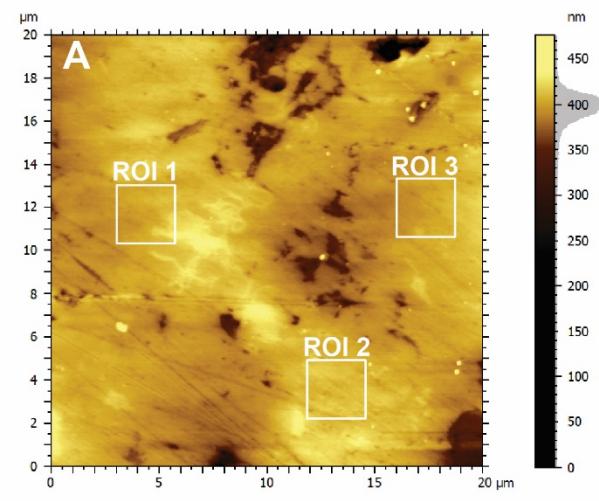
- ❑ Kimmeridge Clay Fm.
 - ❑ 44 wt.% TOC, 0.42% VR_o
 - ❑ 0.29% BR_o, 737 HI
 - ❑ bituminite, vitrinite, solid bitumen, inertinite, micrinite, sulfides
 - ❑ 0.035 S_{org}/C (6.63 wt.% org. S)



- Pre-milling: bituminite reflectance 0.18% (s.d. 0.02, n=100)
- Post-milling: bituminite reflectance 0.38% (s.d. 0.03, n=100)

- Response to broad ion beam milling
- Reflectance increase
- Differential milling based on hardness
- BIB-induced surface flattening measured by AFM

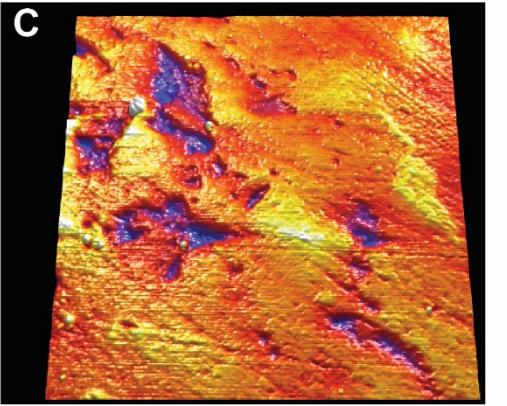




D ISO 25178

Height Parameters

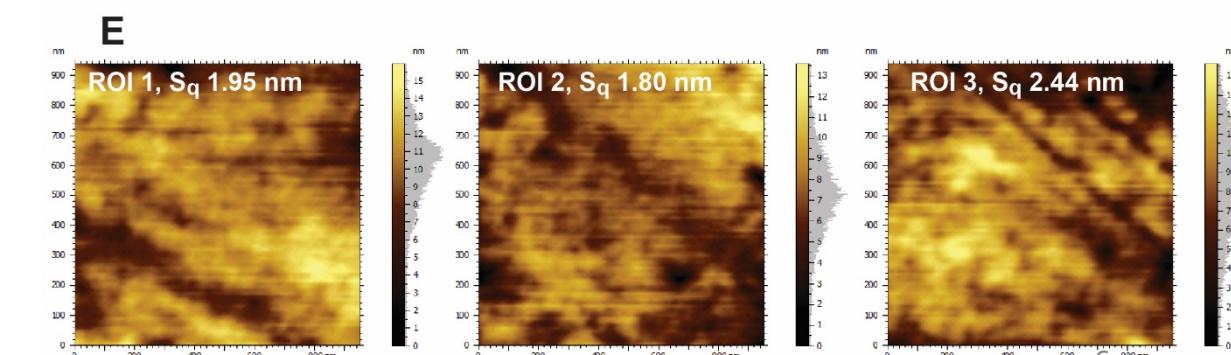
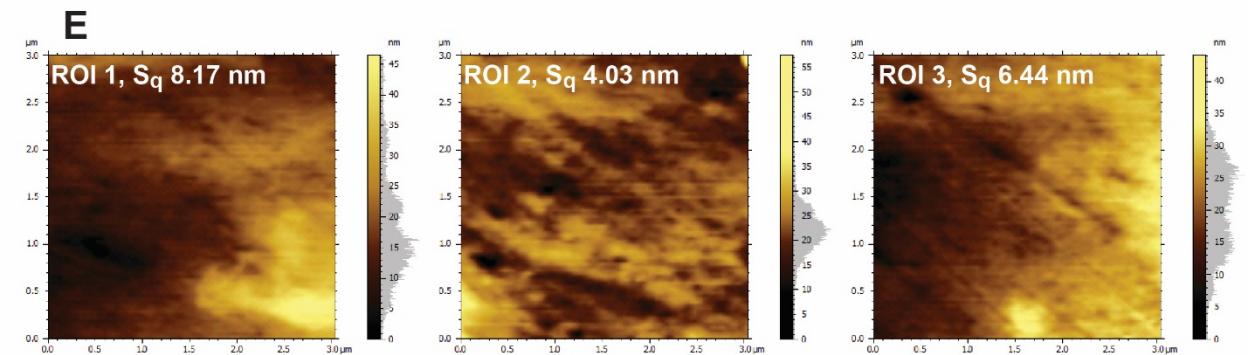
Sq	22.0	nm	Root-mean-square height
Ssk	-4.48		Skewness
Sku	46.9		Kurtosis
Sp	81.9	nm	Maximum peak height
Sv	395	nm	Maximum pit height
Sz	477	nm	Maximum height
Sa	13.3	nm	Arithmetic mean height

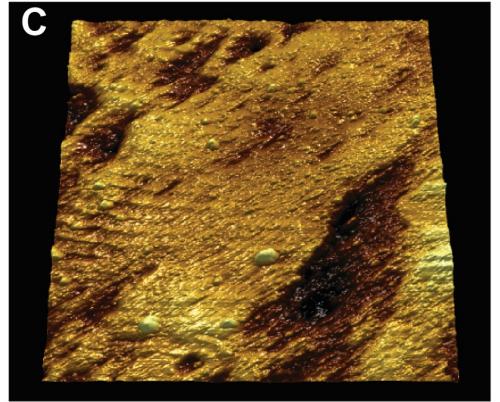
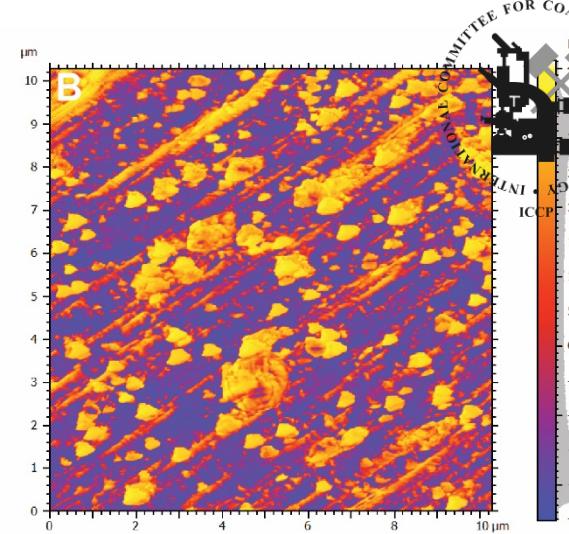
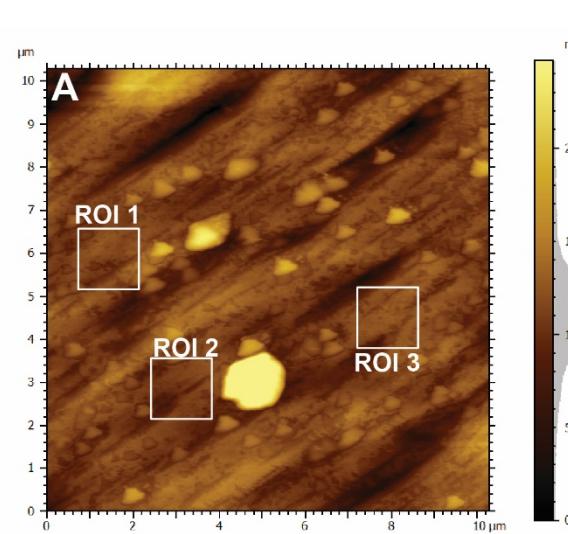
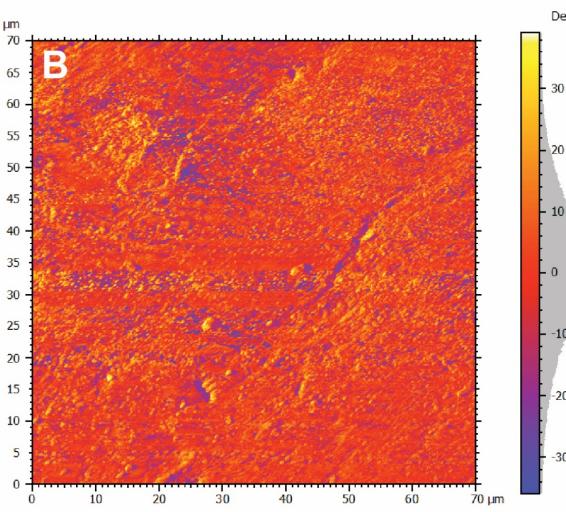
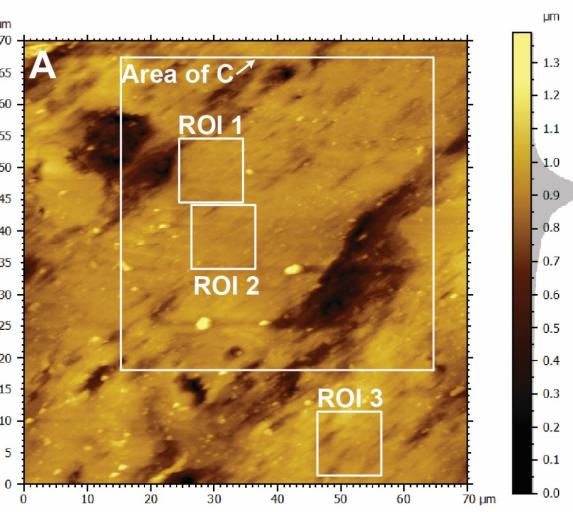


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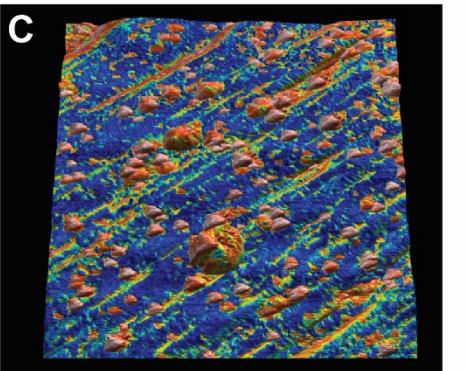
Height Parameters

Sq	9.57	nm	Root-mean-square height
Ssk	-1.68		Skewness
Sku	12.2		Kurtosis
Sp	93.2	nm	Maximum peak height
Sv	77.0	nm	Maximum pit height
Sz	170	nm	Maximum height
Sa	6.08	nm	Arithmetic mean height

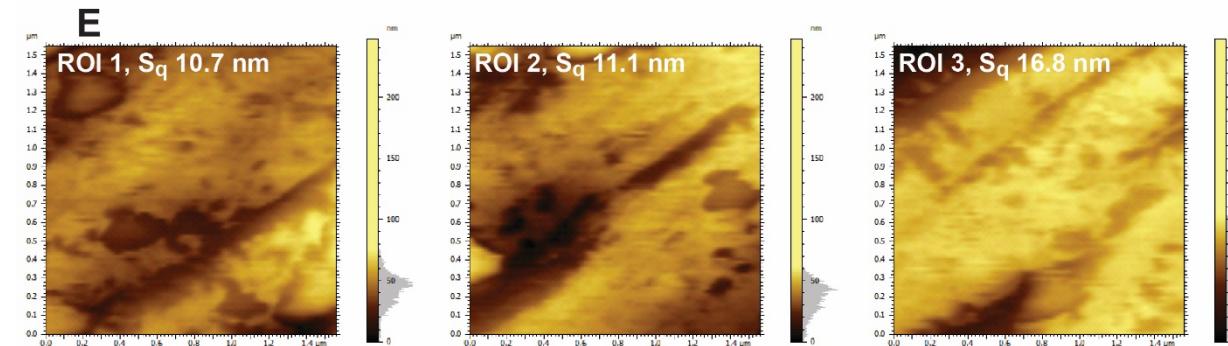
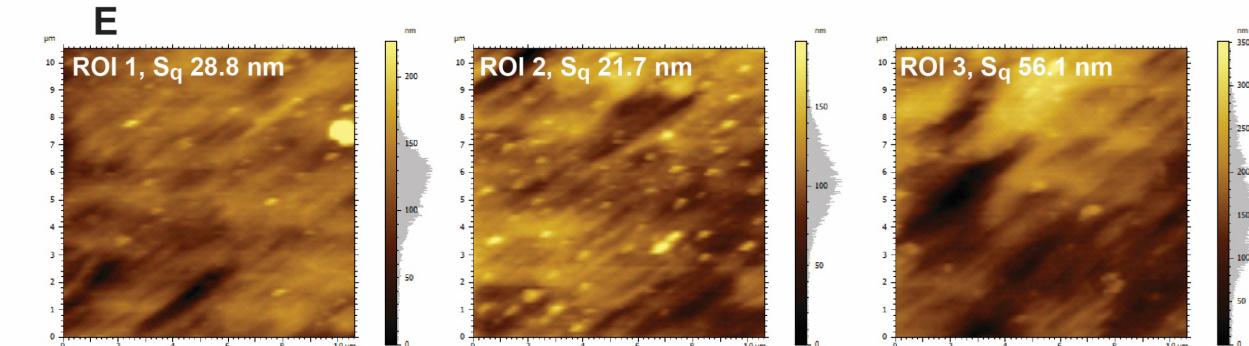


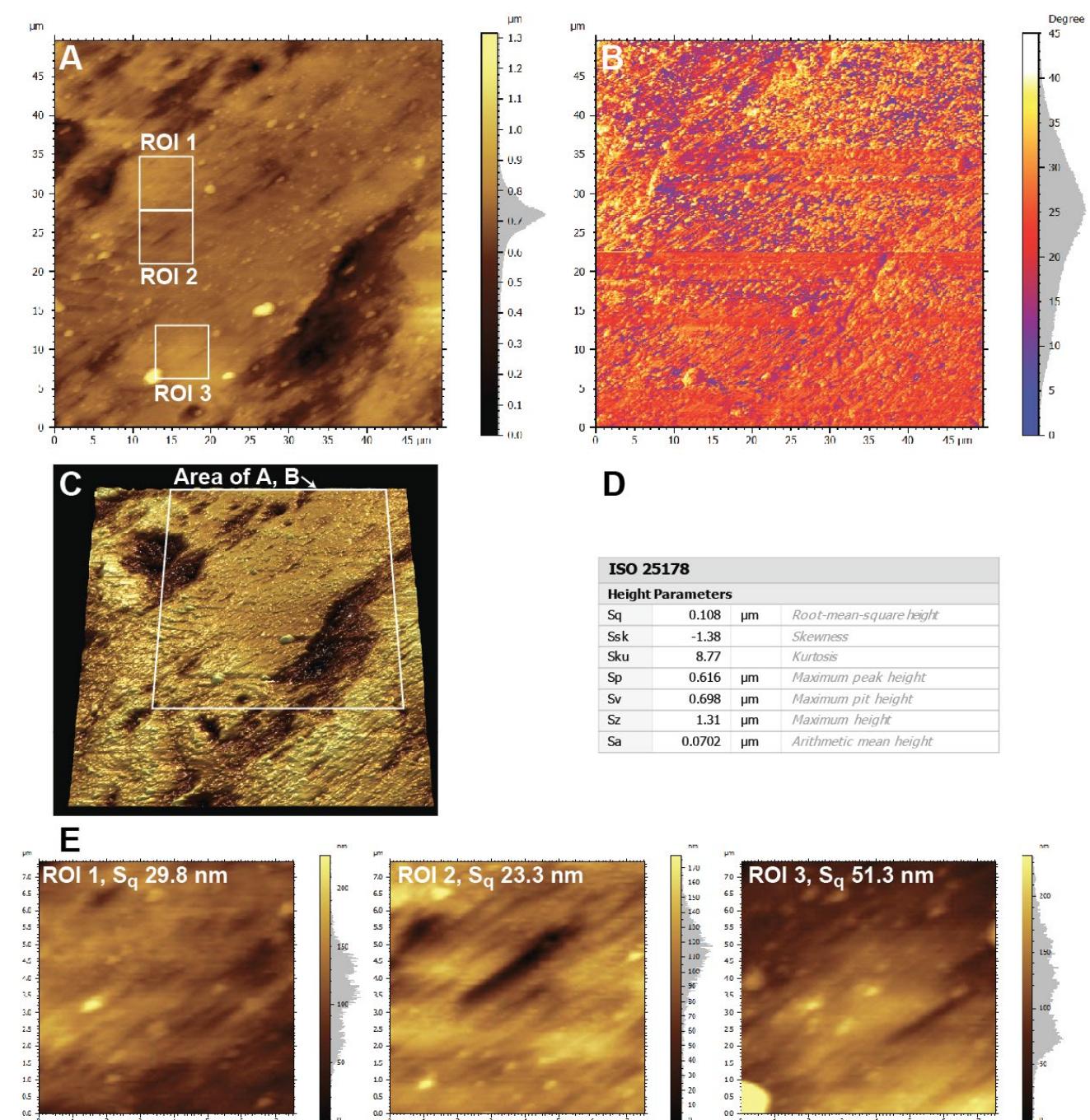


ISO 25178			
Height Parameters			
Sq	0.121	μm	<i>Root-mean-square height</i>
Ssk	-1.84		<i>Skewness</i>
Sku	8.07		<i>Kurtosis</i>
Sp	0.525	μm	<i>Maximum peak height</i>
Sv	0.865	μm	<i>Maximum pit height</i>
Sz	1.39	μm	<i>Maximum height</i>
Sa	0.0844	μm	<i>Arithmetic mean height</i>



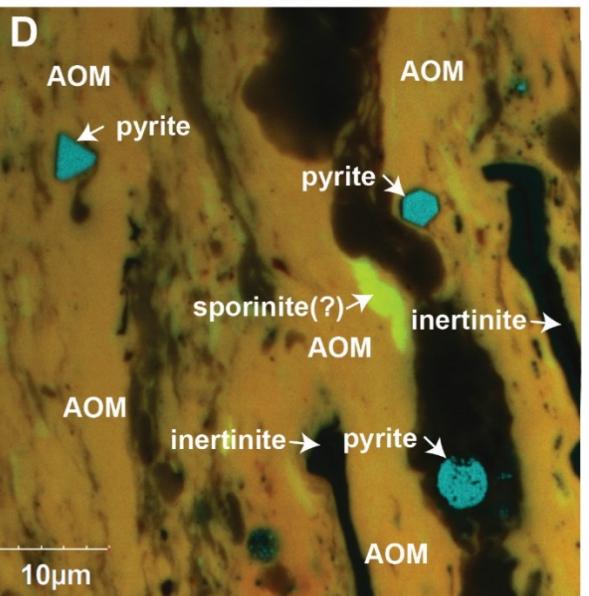
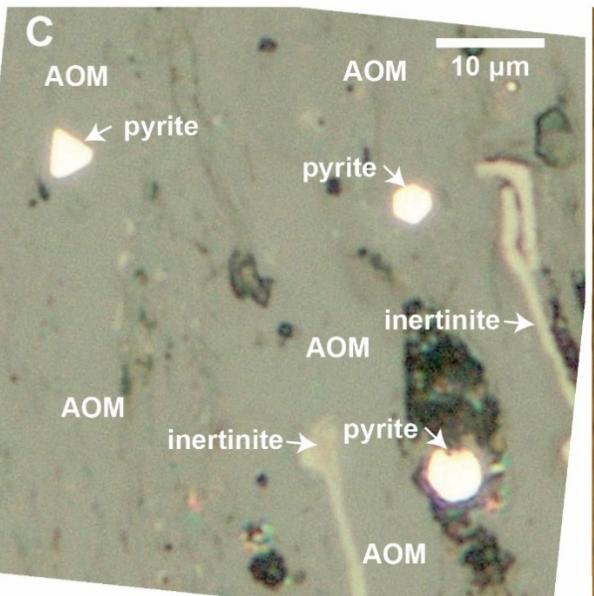
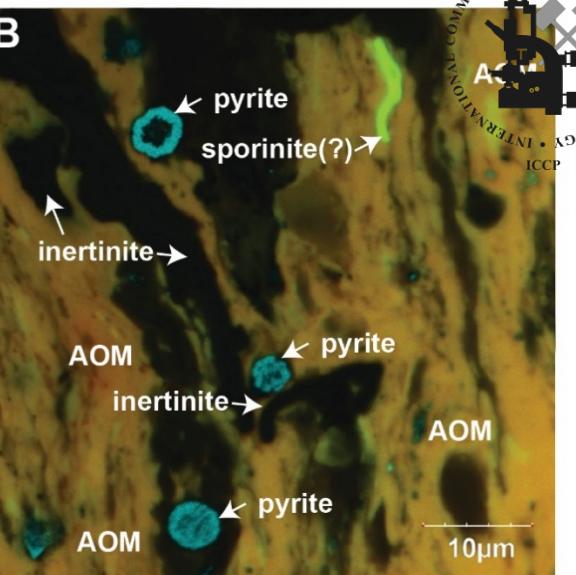
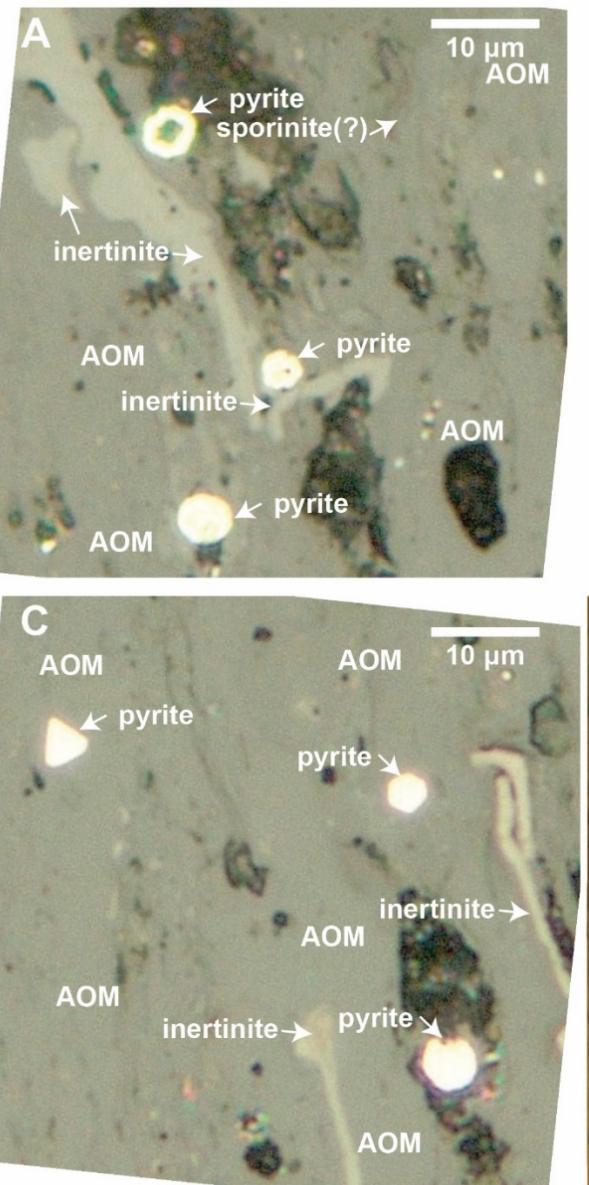
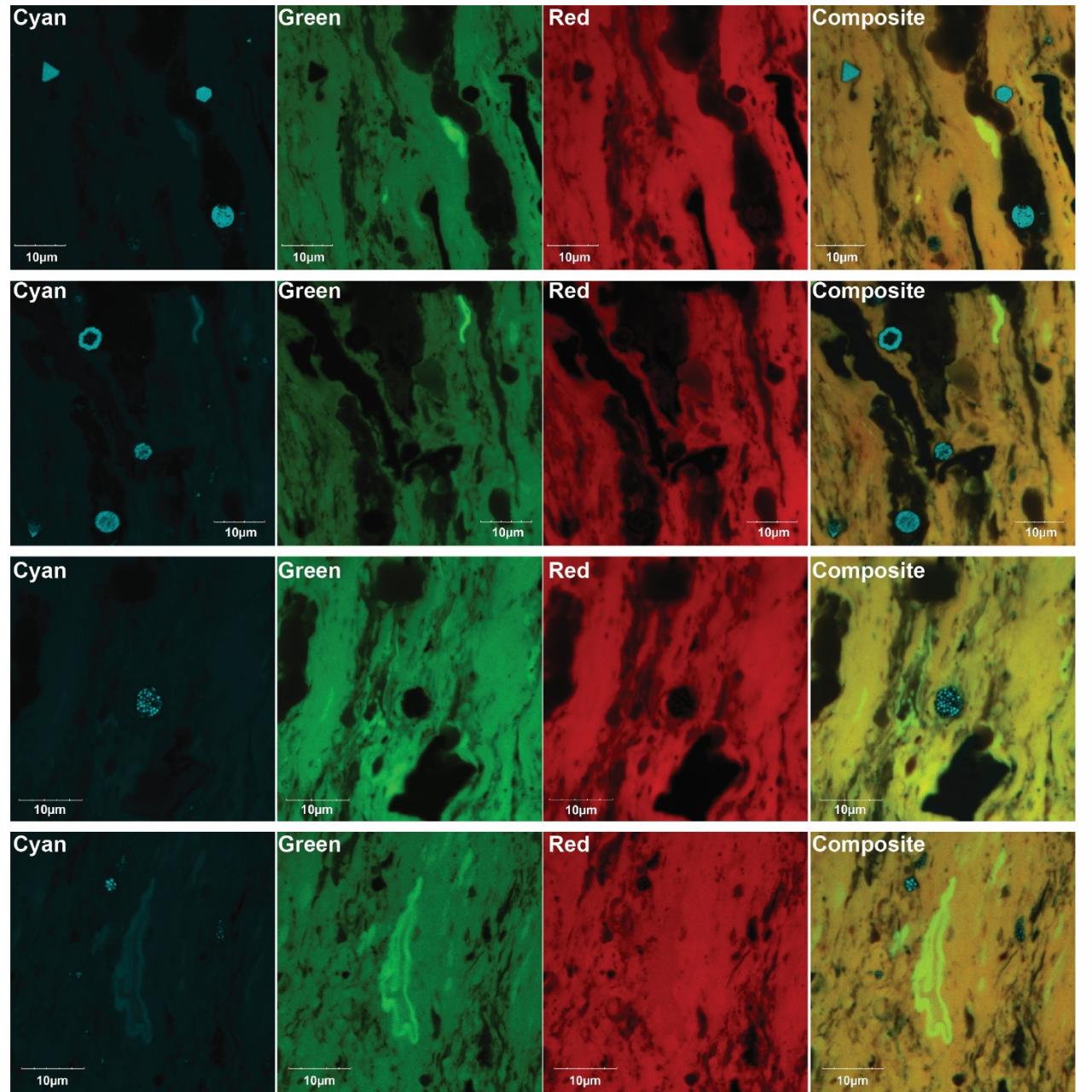
ISO 25178			
Height Parameters			
Sq	136	nm	<i>Root-mean-square height</i>
Ssk	0.011		<i>Skewness</i>
Sku	2.18		<i>Kurtosis</i>
Sp	331	nm	<i>Maximum peak height</i>
Sv	342	nm	<i>Maximum pit height</i>
Sz	672	nm	<i>Maximum height</i>
Sa	114	nm	<i>Arithmetic mean height</i>



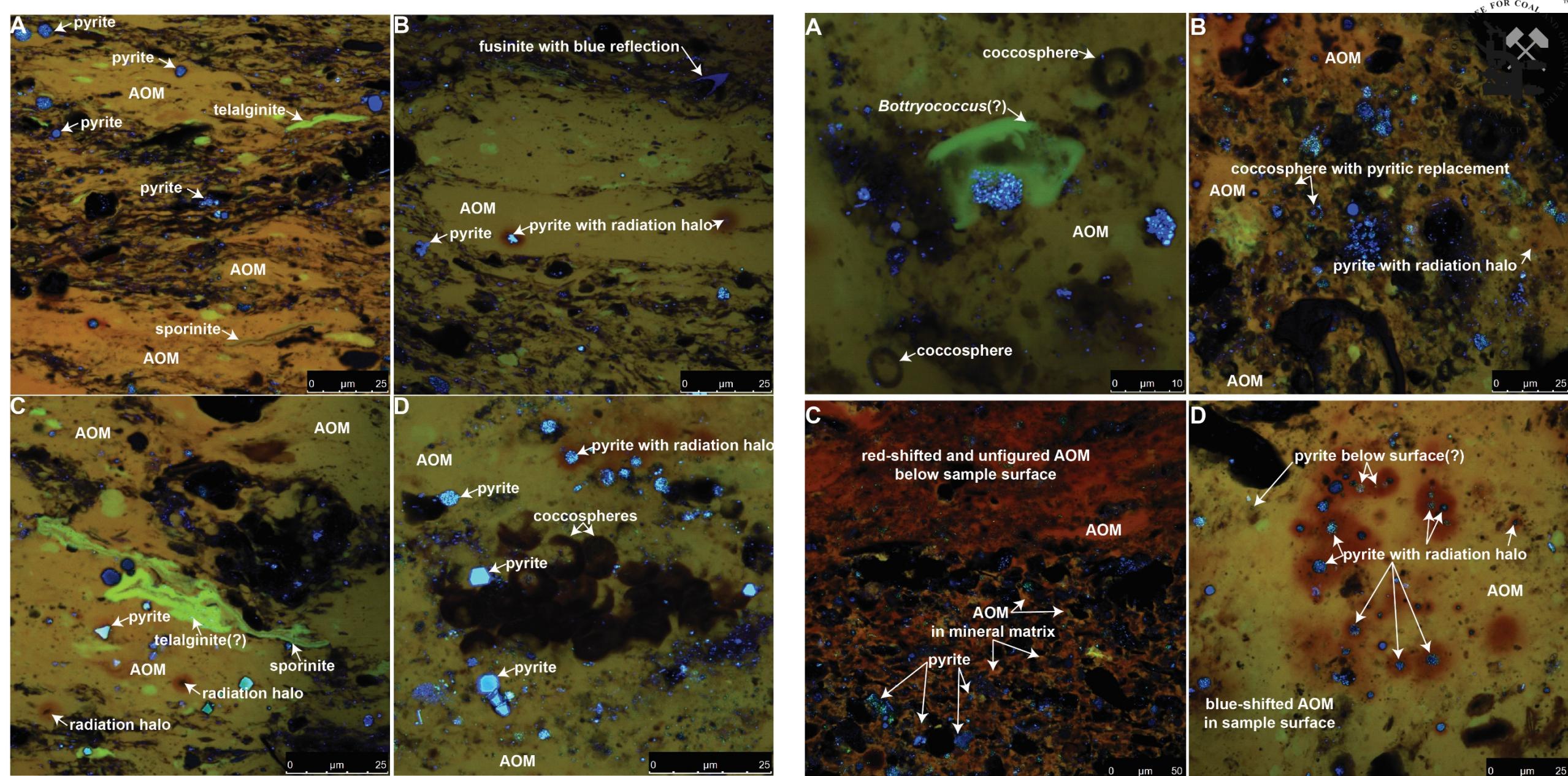


BIB/AFM Summary

- Reflectance increase after BIB milling
- Differential milling based on hardness – exposure of nano-sulfides, quartz
- BIB-induced surface flattening of bituminite measured by correlative AFM
- BIB-induced surface roughening caused by differential milling
- Wider distribution of mechanical properties post-milling, exposure of nano-sulfides
- Smearing of OM during mechanical polish disguises nano-sulfides(?)
- Scale of observation matters: smaller fields give lower S_q
- More work is required



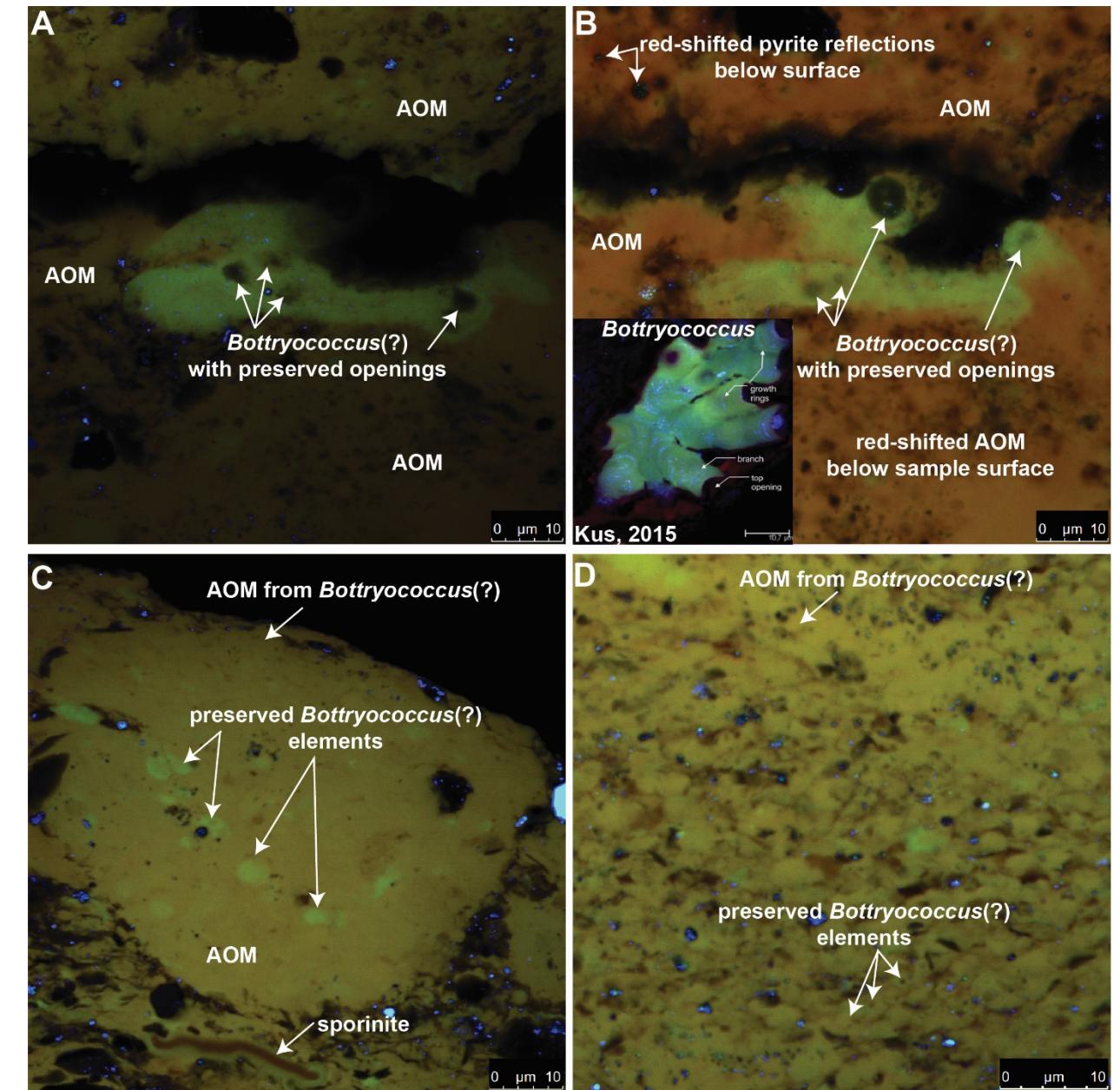
- ❑ Construction of 3-channel false color images
- ❑ Reflectance of 458 nm laser from sulfides



□ Reflectance of 458 nm laser from sulfides
 □ U substitution for Fe: radiation halos

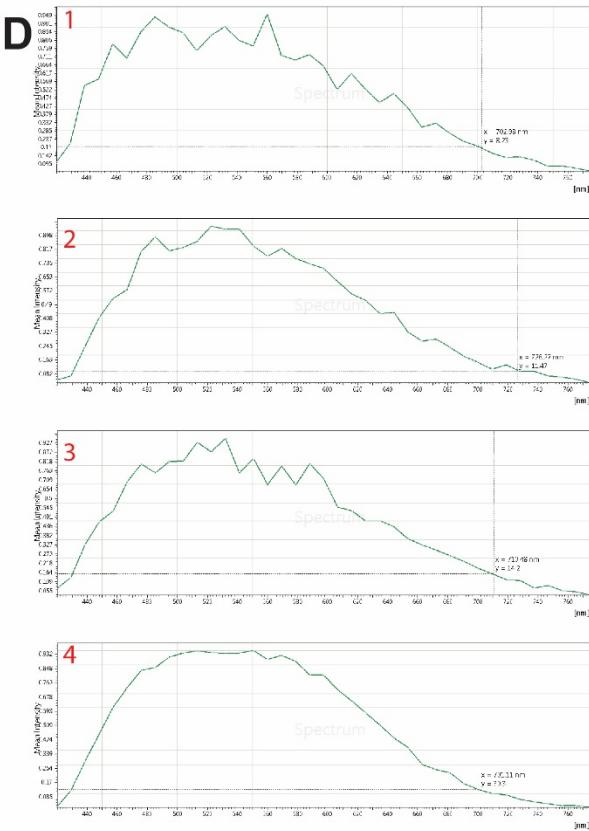
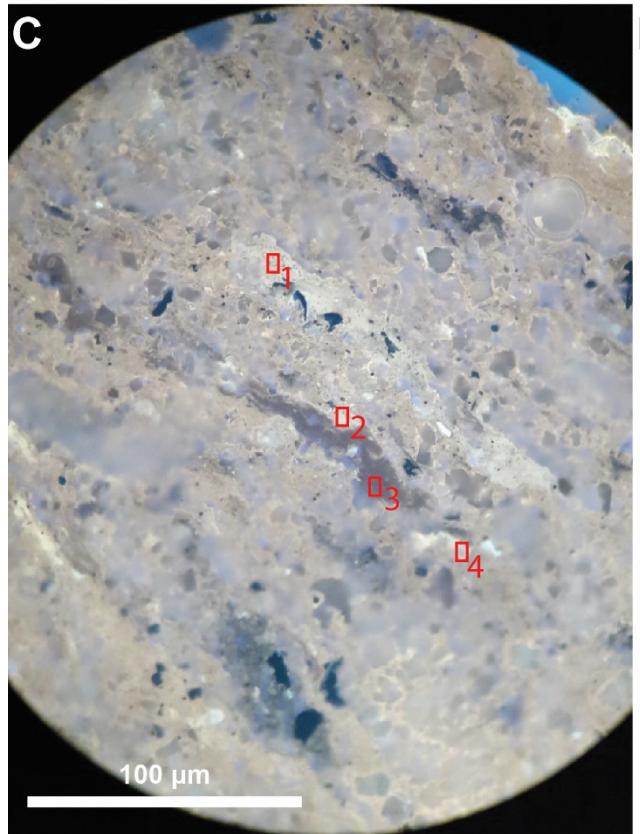
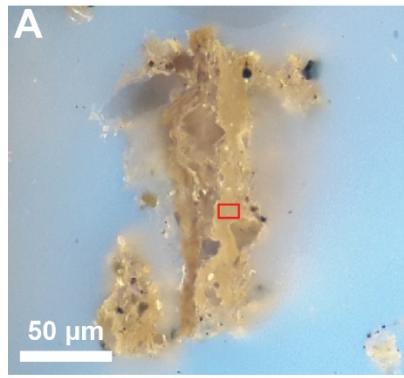
□ *Botryococcus*(?)
 □ Red-shifted fluorescence/reflectance below ₁₀ surface

CLSM Imaging Summary



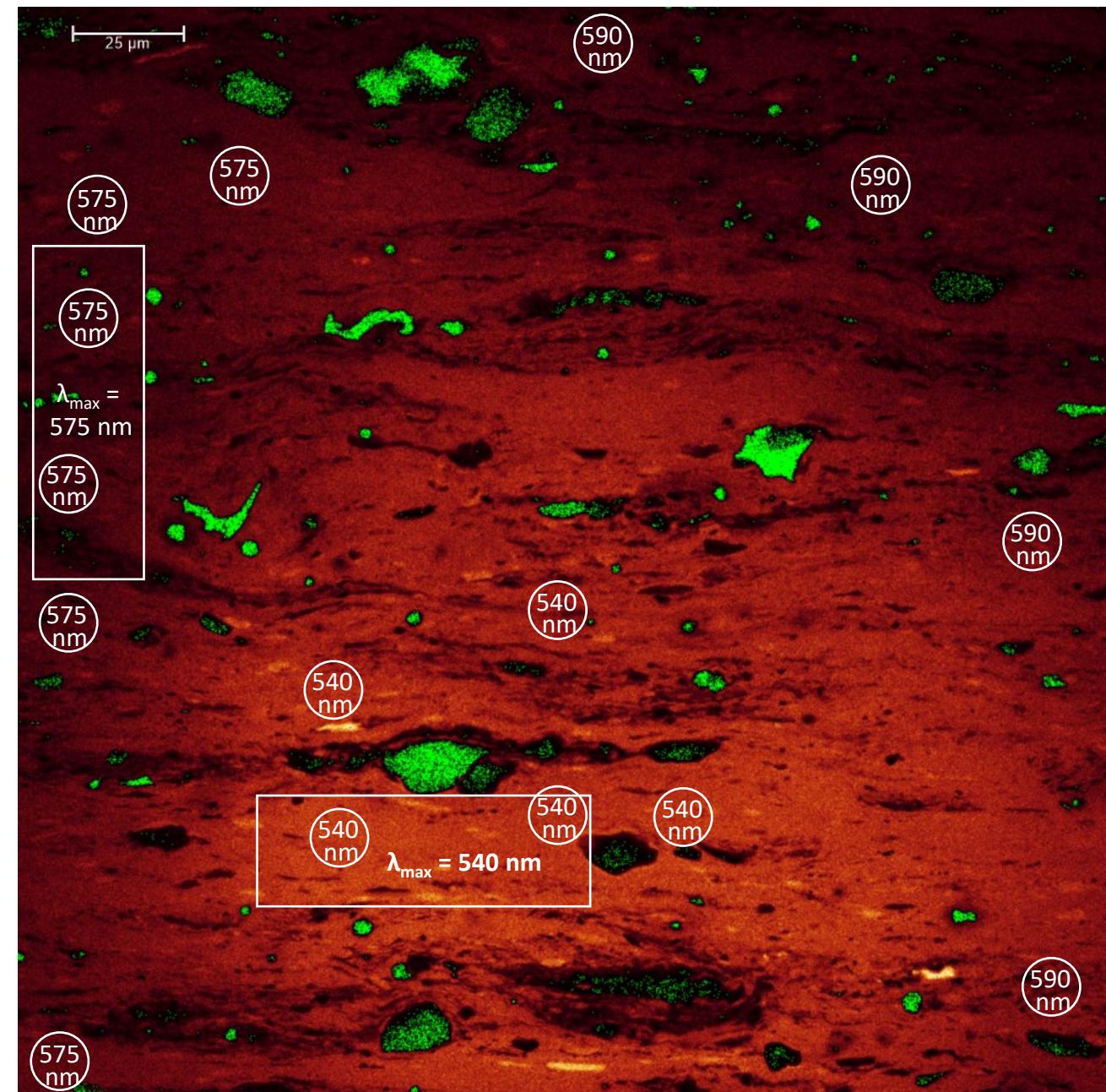
- Reflectance of 458 nm laser
- U substitution for Fe
- *Botryococcus(?)*
- Red-shifted fluorescence and reflectance below sample surface

CLSM Spectroscopy

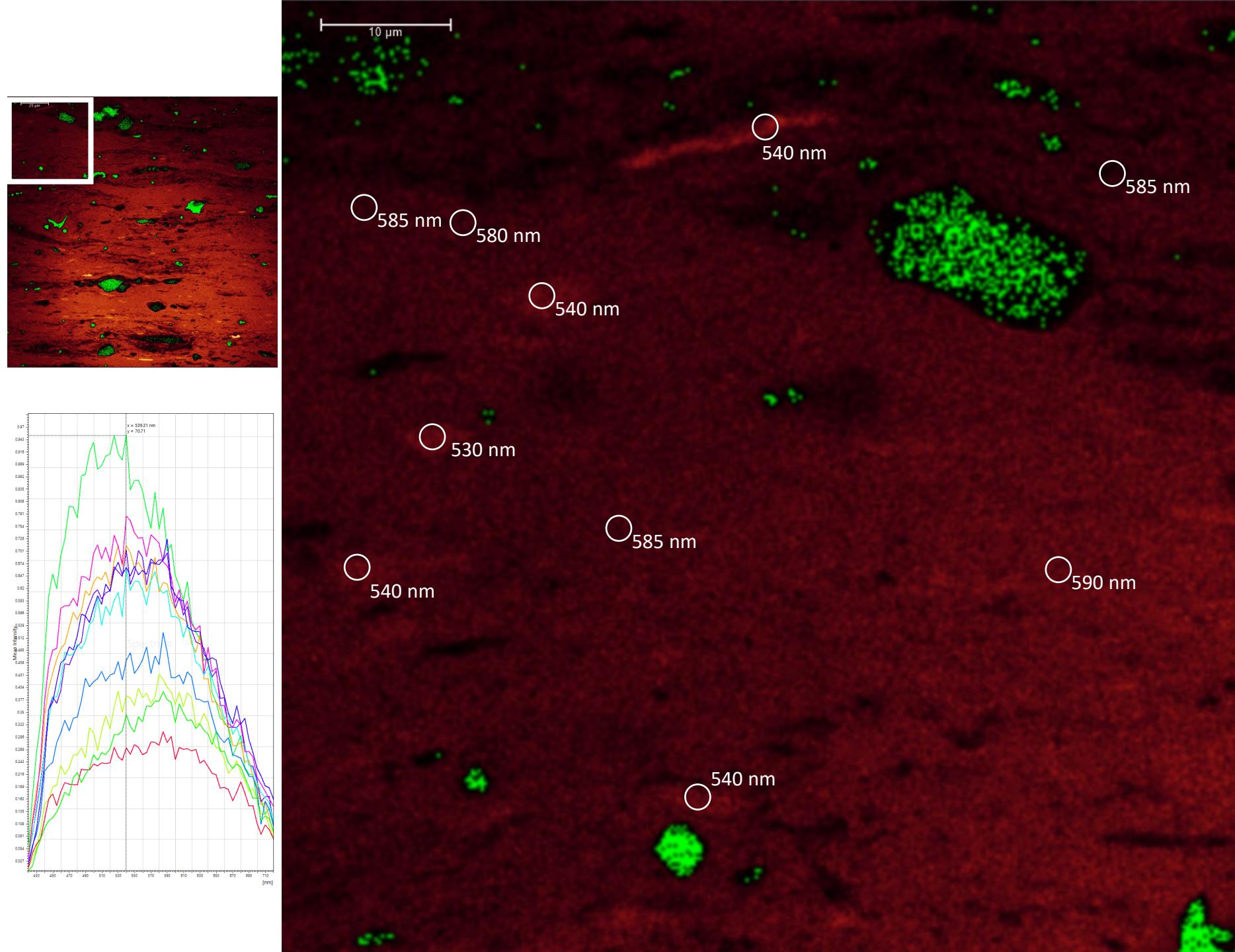


- B: λ_{\max} 562 nm (405 nm diode)
- Calc. BR_o 0.29% (Stasiuk, 1994)
- B+D: Avg. λ_{\max} 539 nm (n=5)
- Calc. BR_o 0.21% (Stasiuk, 1994)

CLSM Spectroscopy

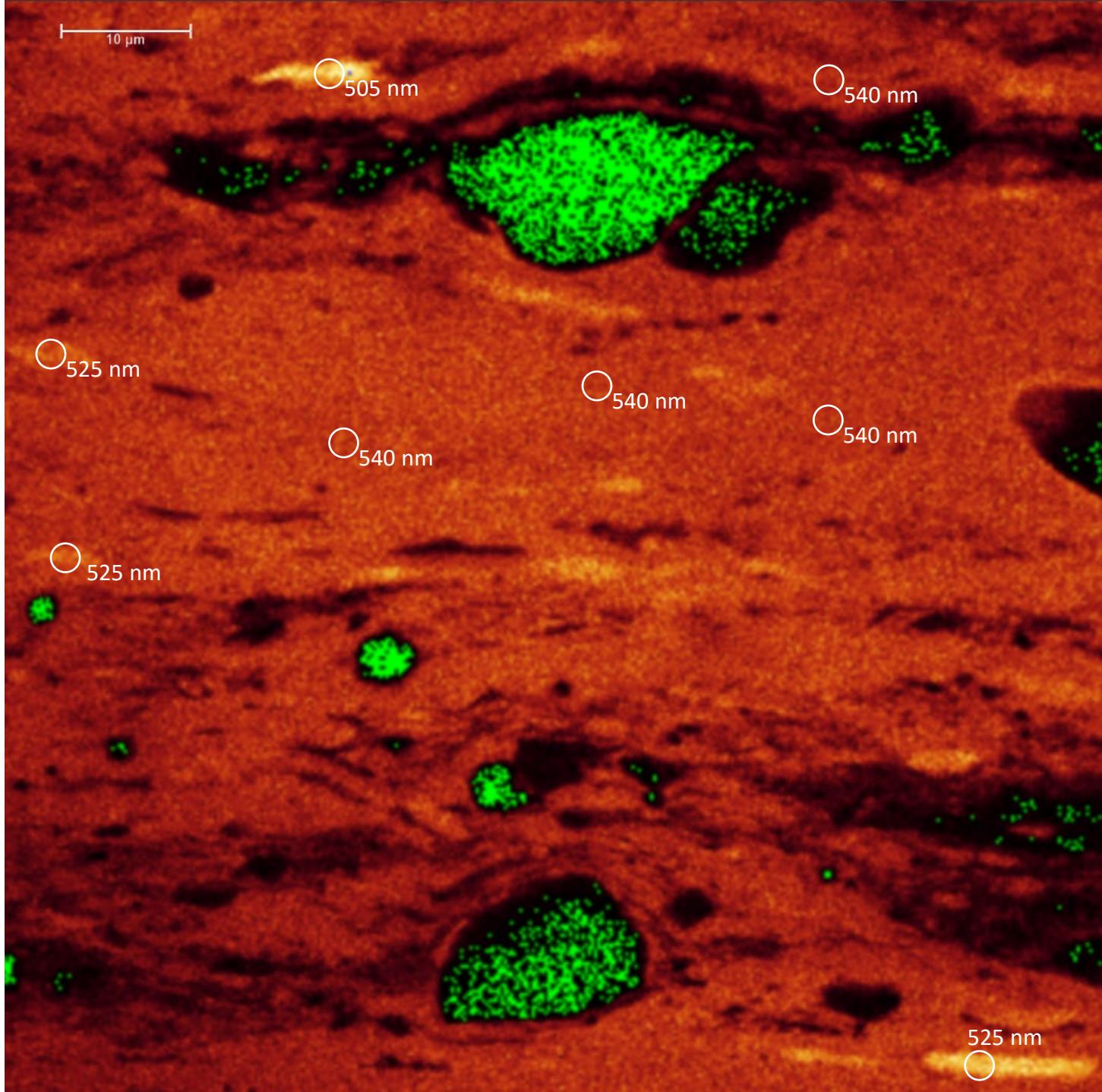


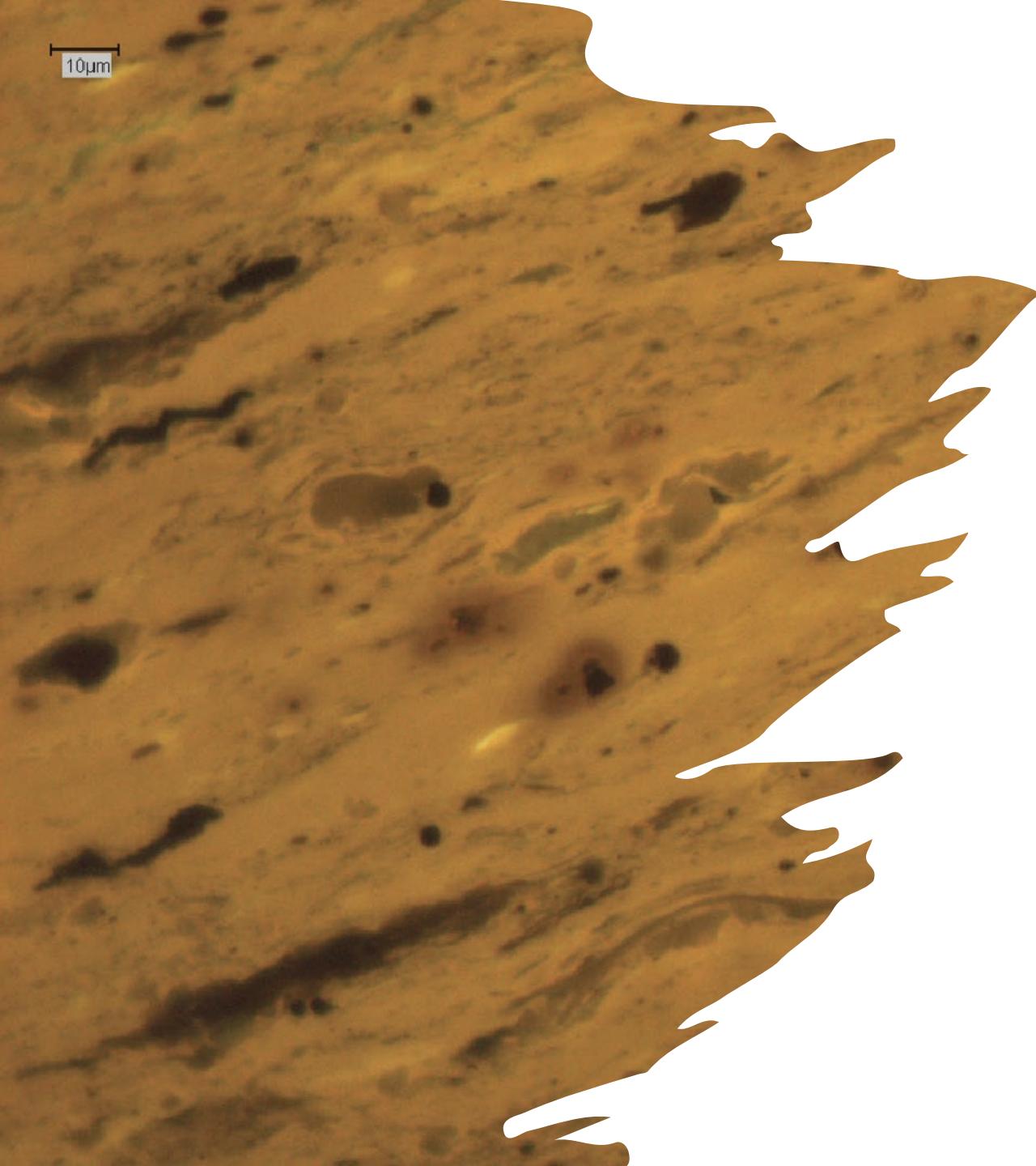
- Unintentional photo-oxidation
- Unaltered λ_{\max} 575 nm
- Altered λ_{\max} 540 nm
- Calc. BR_o 0.32% (Stasiuk, 1994)
from unaltered area



- Unaltered region
- Higher emission intensity blue-shift
- $\lambda_{\max} 538 \text{ nm}$, avg. high intensity
- $\lambda_{\max} 585 \text{ nm}$, avg. lower intensity

- Altered region
- Higher emission intensity blue-shift
- λ_{\max} 520 nm, avg. high intensity
- λ_{\max} 540 nm, avg. lower intensity





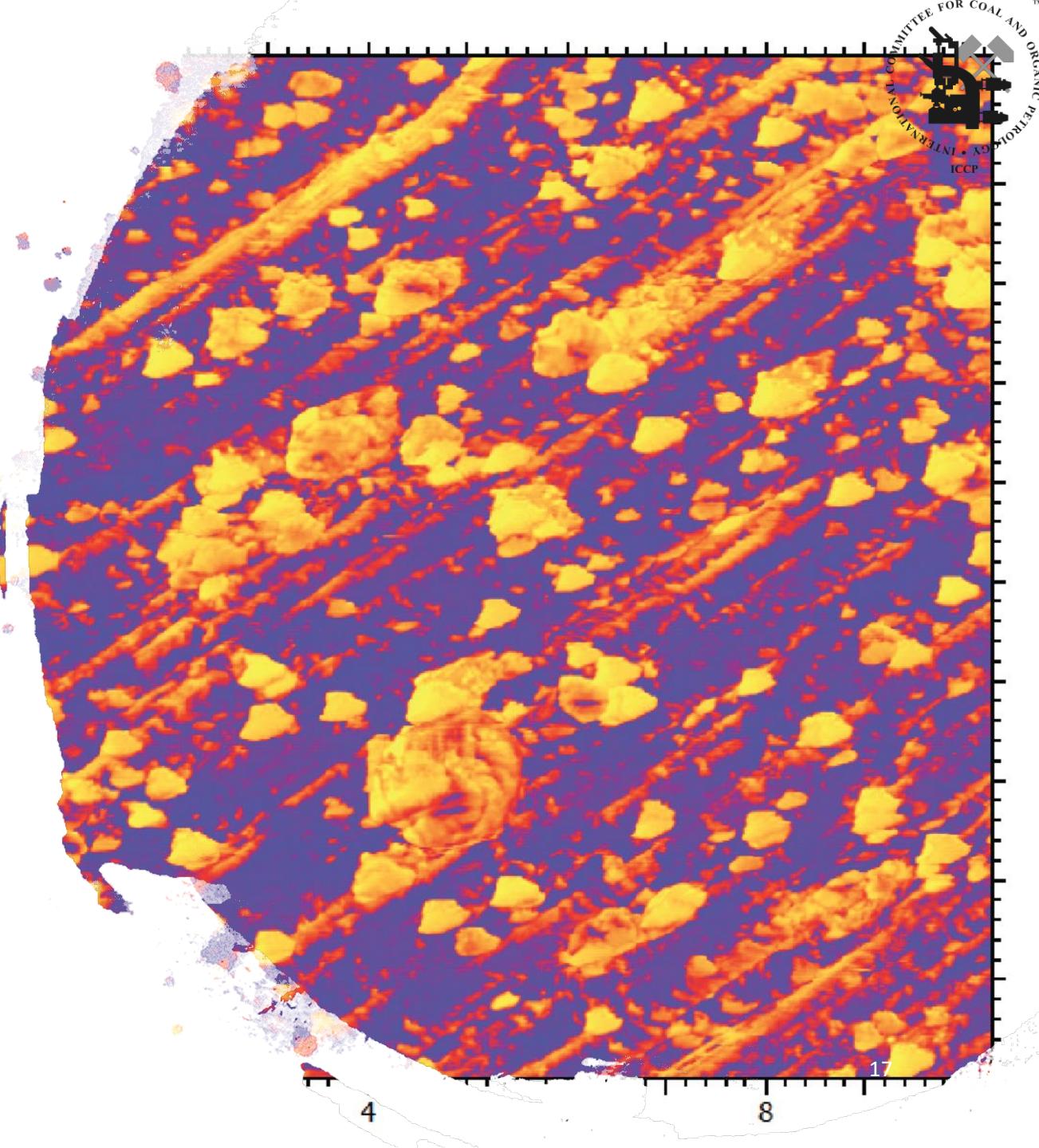
10 μ m

Summary

- ❑ KC sample characterized by AFM, CLSM
- ❑ Differential milling via BIB
- ❑ Reflectance increase via BIB
- ❑ CLSM identified *Botryococcus*(?)
- ❑ Reflectance of 458 nm laser
- ❑ Red-shift of reflectance and fluorescence from below surface
- ❑ λ_{max} measurement requires standardization
- ❑ Empirical relation from Stasiuk matches measured BR_o
- ❑ Photooxidation causes positive alteration, color blue-shift

Next Steps

- Provide final CLSM WG report
- Update webpage
- Notification to ICCP News
- Peer-reviewed manuscript





Thanks ICCP!

Paul C. Hackley, USGS, phackley@usgs.gov

Jolanta Kus, BGR, jolanta.kus@bgr.de